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8 82 Sheet 1 of 2

Form PTO-1449		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE			ATTY. DOCKET NO. MI22-1965	SERIAL NO. Unknown		
LIST OF ART CITED BY APPLICANT (Use several sheets if necessary)					APPLICANT Jigish D. Trivedi et al.			
					FILING DATE Filed herewith		GROUP Unknown	
U.S. PATENT DOCUMENTS								
*Examiner Initial		Document Number	Date	Name		Class	Subclass	Filing Date If Appropriate
WFO	AA	5,254,489	10/19/93	Nakata		437	40	
	AB	5,464,792	11/7/95	Tseng et al.		437	160	
	AC	5,620,908	4/15/97	Inoh et al.		438	207	
	AD	5,716,864	2/10/98	Abe		437	43	
	AE	5,972,783	10/26/99	Arai et al.		438	513	
	AF	5,674,788	10/1997	Wristers et al.		437	239	
	AG	5,960,302	09/1999	Ma et al.		438	585	
	AH	5,994,749	11/1999	Oda		257	411	
	AI	6,225,151 B1	05/2001	Gardner et al.		438	162	
	AJ	4,651,406	03/1987	Shimizu et al.		29	571	
WFO	AK	5,502,009	03/1996	Lin		437	239	
FOREIGN PATENT DOCUMENTS								
		Document Number	Date	Country		Class	Subclass	Translation
								Yes
	AL	6302813 A	04/1993	Japan				No
	AM	WO 96/39713	6/1996	Wristers et al.				
	AN							
	AO							
	AP							
OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, Etc.)								
WFO	AR		C.T. Liu et al.; "Multiple Gate Oxide Thickness for 2GHz System-on-A-Chip Technologies"; IEEE 1998; pp. 21.2.1-21.2.4					
WFO	AS		Kuroi et al., "The Effects of Nitrogen Implantation Into P + Poly-Silicon Gate on Gate Oxide Properties", 1994 Symposium on VLSI Technology Digest of Technical Papers, pp. 107-108.					
WFO	AT		Doyle et al., "Simultaneous Growth of Different Thickness Gate Oxides in Silicon CMOS Processing", IEEE Electron Device Letters, Vol. 16, No. 7.					
EXAMINER Douglas W. Owens			DATE CONSIDERED 7/14/02					

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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U.S. PATENT DOCUMENTS									
*Examiner Initial		Document Number	Date	Name		Class	Subclass	Filing Date If Appropriate	
<i>DKO</i>	AA	6,136,654	10/2000	Kraft et al.		438	287		
<i>DKO</i>	AB	6,165,846	12/2000	Carns et al.		438	264		
<i>DKO</i>	AC	6,200,834 B1	03/2001	Bronner et al.		438	142		
	AD								
	AE								
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	AG								
	AH								
	AI								
	AJ								
	AK								
FOREIGN PATENT DOCUMENTS									
		Document Number	Date	Country		Class	Subclass	Translation	
								Yes	No
	AL								
	AM								
	AN								
	AO								
	AP								
OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, Etc.)									
<i>DKO</i>	AR		Ko et al., "The Effect of Nitrogen Incorporation Into the Gate Oxide by Using Shallow Implantation of Nitrogen and Drive-in Process", 1998 IEEE, 0-7803-4932-6/98.						
	AS								
	AT								
EXAMINER <i>Douglas W. Oren</i>				DATE CONSIDERED <i>7/11/02</i>					
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Form PTO-1449		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. M122-1965		SERIAL NO. 10/087,416		
LIST OF ART CITED BY APPLICANT (Use several sheets if necessary)				APPLICANT Jigish D. Trivedi et al.				
				FILING DATE Filed herewith		GROUP 2811		
PATENT DOCUMENTS PATENT & TRADEMARK OFFICE								
*Examiner Initial		Document Number	Date	Name		Class	Subclass	Filing Date If Appropriate
	AA							
	AB							
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	AJ							
	AK							
FOREIGN PATENT DOCUMENTS								
		Document Number	Date	Country	Class	Subclass	Translation	
							Yes	No
	AL	326352-A	2001	Japan (Abstract provided w/untranslated patent)			Yes	No
	AM							
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OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, Etc.)								
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LIST OF ART CITED BY APPLICANT (Use several sheets if necessary)				APPLICANT Jigish D. Trivedi et al.			
				FILING DATE February 27, 2002	GROUP 2811		
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*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
DKO	AA	5,596,218	01/1997	Soleimani et al.			
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DKO	AC	5,763,922	06/1998	Chau			
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	AE						
	AF						
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	AJ						
	AK						
FOREIGN PATENT DOCUMENTS							
		Document Number	Date	Country	Class	Subclass	Translation
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